

**EXPEDITED PROCEDURE**

ART UNIT: 1794

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

APPLICANT:	Kurt, R.	Attn. Doc. No.: NL 021426 US1
SERIAL NO.:	10/539,362	EXAMINER: Mulvaney, E. E.
FILED:	June 15, 2005	ART UNIT: 1794
		CONFIRMATION No.: 7350

***FOR: USE OF bi-LAYER PHOTOLITHOGRAPHIC RESISTS AS NEW  
MATERIAL FOR OPTICAL STORAGE***

Mail Stop AF  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**AMENDMENT AFTER FINAL OFFICE ACTION**

Dear Sir:

In response to the Final Office Action dated May 7, 2009, the Applicant hereby submits this paper within two (2) months (until **July 7, 2009**) of the mailing date of the Office Action, and requests amendment of the above-identified application as follows wherein:

**Amendments** made to the Claims begin on page 2, and

**Remarks** begin on page 9.

As this paper is being filed within two (2) months of the mailing date of the instant Office Action, applicant respectfully requests that the entry of this paper into the record be expedited to allow the Examiner sufficient time to review the arguments presented herein within the statutory time period.